



1731
PATENTS

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Akio FUJIMURA et al.

Serial No. 09/863,297

GROUP 1731

Filed May 24, 2001

METHOD FOR THE PRODUCTION OF
GLASS SUBSTRATES FOR MAGNETIC
RECORDING MEDIUMS

#3/BM
8-29-01

TO 1700 MAIL ROOM

AUG 29 2001

RECEIVED

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents

Washington, D.C. 20231

Sir:

In compliance with Rules 1.97 and 1.98, and in fulfillment of the duty of disclosure under Rule 1.56, the accompanying documents, copies of which are attached to this statement, are made of record on the enclosed sheet.

A concise explanation of the relevance of these items is that these references were discovered during any searches they or their client had made, or that they were considered in the preparation of the application.

Respectfully submitted,

YOUNG & THOMPSON

By

Benoît Castel

Benoît Castel
Attorney for Applicants
Registration No. 35,041
745 South 23rd Street
Arlington, VA 22202
Telephone: 703/521-2297

August 24, 2001

FORM PTO-1449 U.S. DEPARTMENT OF COMMERCE
PATENT AND TRADEMARK OFFICE

ATTY. DOCKET NO.

W-2690

SERIAL NO.

09/863,297

**INFORMATION DISCLOSURE
STATEMENT BY APPLICANT**

(Use several sheets if necessary)

(37 CFR 1.98(b))

APPLICANT

Akio FUJIMURA et al.

FILING DATE

May 24, 2001

GROUP

1731

U.S. PATENT DOCUMENTS

EXAMINER INITIAL		PATENT NUMBER	ISSUE DATE	PATENTEE	CLASS	SUB CLASS	FILING DATE IF APPROPRIATE
	AA						
	AB						
	AC						
	AD						
	AE						
	AF						
	AG						
	AH						
	AI						
	AJ						
	AK						

FOREIGN PATENT OR PUBLISHED FOREIGN PATENT APPLICATION

		DOCUMENT NO.	PUBL. DATE	COUNTRY OR PATENT OFFICE	CLASS	SUB CLASS	TRANSLATION YES NO
	AL	3-52130	3/91	Japan			English abstract
	AM	7-134823	5/95	Japan			English abstract
	AN	8-124153	5/96	Japan			English abstract
	AO						
	AP						

OTHER DOCUMENTS (Including Author, Title, Date, Relevant Pages, Place of Publication)

	AR	
	AS	
	AT	

EXAMINER

DATE CONSIDERED

EXAMINER: Initial citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.